

FORM PTO-1449 INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)	Docket Number (Optional)	Application Number
	900.8463USU	09/334,386
	Applicant	
	Wiedeman et al.	
Filing Date	Group Art Unit	
June 16, 1999	2731	

U. S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
MS	5,610,595	3/11/97	Garrabrant et al.	340	825.52	
MS	5,151,899	9/29/92	Thomas et al.	370	94.1 394.000	

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FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO
MS	WO 98/16046	4/16/98	PCT	H04L	29/06		

OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, Etc.)

MS	European Search Report dated September 3, 2001, from corresponding European Patent Application No. 00300535.

EXAMINER 	DATE CONSIDERED 6/28/03
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP §609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

**INFORMATION DISCLOSURE
CITATION FORM FOR
PATENT APPLICATION
(FORM PTO-1449)
(Substitute)**

Docket No.: 300P008463-US(PAR)

Serial No.:

Applicant(s): Wiedeman et al.

Filing Date: Herewith

Group:

U.S. PATENTS

Initials	Patent Number	Issue Date	Name	Class	Sub-class	Filing date
MS	5,410,728	4/25/95	Bertiger et al.	455	13.1	4/21/93
MS	5,736,959	4/7/98	Patterson et al.	342	354	4/17/95
MS	5,740,164	4/14/98	Liron	370	316	6/7/95
MS	5,796,715	8/18/98	Patterson et al.	370	60 349	5/12/94

FOREIGN PATENT DOCUMENTS

Initials	Document Number	Date	Country	Name	Translation? Yes/No/n/a

OTHER DOCUMENTS (Title, Author, Date, Pages, Etc., if known)

Examiner's Signature: *Delana Jagan*

Date Considered: 6/30/02

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